

## Effect of Seed Crystal on Zirconium Oxide Formation From Aqueous Solution

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Effect of seed crystal on the formation of  $ZrO_2$  from aqueous solution was investigated. A glass substrate was soaked in  $Na_2ZrF_6$  and  $H_3BO_3$  mixed aqueous solution for 3 d with or without  $ZrO_2$  seed crystals. Without seed crystal, no  $ZrO_2$  was formed on the substrate. With seed crystals,  $ZrO_2$  formation was observed and the XRD peak intensity increased with increasing amount of seed crystals in the mixed solution. This indicates that the seed crystal is indispensable for  $ZrO_2$  formation from  $Na_2ZrF_6$  and  $H_3BO_3$  mixed aqueous solution. Ultrasonic vibration for suitable period enhanced the formation of  $ZrO_2$ . Growth and connection of  $ZrO_2$  particles were observed in SEM micrograph on the substrate.

Key words: Zirconium oxide, Aqueous solution, Seed crystal, Fluoro complex

## 1. INTRODUCTION

Zirconium oxide ( $ZrO_2$ ) has been used as a functional material with wide range of application.  $ZrO_2$  is a candidate of gate insulator material with high dielectric constant replacing presently used silicon dioxide in the next generation of MOS-FET [1].  $ZrO_2$  also has a potential application as a biomaterial because it has an ability to induce formation of bone-like high biocompatible hydroxyapatite [2]. Also, zirconium oxide solid solutions have high oxide ion conductivity and used for oxygen sensor, solid oxide fuel cell (SOFC), oxygen separation membrane and so on [3]. For the practical application of  $ZrO_2$ , technique for thin film formation is important.

$ZrO_2$  thin film was prepared by sol-gel process [4] or vapor phase process such as chemical vapor deposition [5], sputtering [6] and so on. However, these methods have several disadvantages. Sol-gel process, and chemical vapor deposition require heating, which is injurious because of the possibility of a change in the shape and/or size of the film and of crack formation, and are not applicable for low heat resistant substrates. For sputtering, expensive vacuum equipments are required and the film areas are restricted.

Recently, we have presented methods for forming oxide ceramics from aqueous solution [7-10].  $ZrO_2$  can be formed from aqueous solution at ordinary temperature and ordinary pressure by hydrolysis reaction of zirconium fluoro-complex [7]. This method is advantageous because no vacuum, no high temperature and no expensive apparatus will be required, and substrates, even those with wide areas and/or complicated shapes, are available. The reaction mechanism is considered as follows. The chemical equilibrium between hexafluorozirconate ion and  $ZrO_2$  holds as in reaction (1)



When borate ion is added, fluoride ion is consumed by reaction (2)



Then the chemical equilibrium in reaction (1) is shifted from left to right in order to increase fluoride ions, resulting in the formation of  $ZrO_2$ .

In the present study, the effect of seed crystal on the formation of  $ZrO_2$  from aqueous solution by hydrolysis reaction of zirconium fluoro-complex was investigated.

## 2. EXPERIMENTAL

2.1 Preparation of  $ZrO_2$  seed crystal

$ZrO_2$  powder and distilled water were mixed and left to stand for 1 week. Then supernatant liquid was collected at 20 mm depth from the surface of the water by a pipette. Thus obtained  $ZrO_2$  nano particles were used as seed crystal.  $ZrO_2$  content of the collected supernatant liquid was measured as  $5.5 \times 10^{-4} \text{ mol} \cdot \text{dm}^{-3}$  by a gravimetric method. The diameter of  $ZrO_2$  particles in the collected supernatant was estimated to be less than 110 nm from Stokes' law as equation (3)

$$d = 2 \sqrt{\frac{9\eta h}{2(\rho - \rho_0)gt}} \quad (3)$$

$d$ : diameter of  $ZrO_2$  nano particle

$h$ : sedimentation distance ( $=2.0 \times 10^{-2} \text{ m}$ )

$t$ : sedimentation time ( $=1 \text{ w}=604800 \text{ s}$ )

$\rho$ : density of particle ( $=5.68 \times 10^3 \text{ kg} \cdot \text{m}^{-3}$ )

$\rho_0$ : density of medium ( $=0.998 \times 10^3 \text{ kg} \cdot \text{m}^{-3}$ )

$\eta$ : coefficient of viscosity of medium  
( $=0.001 \text{ kg} \cdot \text{s}^{-1} \cdot \text{m}^{-1}$ )

$g$ : gravitational acceleration ( $9.80 \text{ m} \cdot \text{s}^{-2}$ )

2.2 Formation of  $ZrO_2$ 

Commercial soda-lime slide glass was cut to  $10 \times 15 \times 1 \text{ mm}^3$  in size and used as a substrate. Prescribed amount of  $Na_2ZrF_6$  was dissolved in  $10 \text{ cm}^3$  of distilled water. Prescribed amount of  $H_3BO_3$  was dissolved in  $30 \text{ cm}^3$  of distilled water in which various amount of  $ZrO_2$  nano particle mentioned above was added as seed crystal.

$\text{Na}_2\text{ZrF}_6$  solution was mixed with thus prepared  $\text{H}_3\text{BO}_3$  solution in a plastic bottle. The concentration of  $\text{Na}_2\text{ZrF}_6$  in the mixed solutions was  $9.4 \text{ mmol}\cdot\text{dm}^{-3}$  and the concentration of  $\text{H}_3\text{BO}_3$  was  $28.2 \text{ mmol}\cdot\text{dm}^{-3}$ . The concentrations of  $\text{ZrO}_2$  seed crystals were varied as 0,  $1.4\times 10^{-5}$ ,  $6.9\times 10^{-5}$ ,  $9.6\times 10^{-5}$  or  $1.4\times 10^{-4} \text{ mol}\cdot\text{dm}^{-3}$ . The substrate was suspended in the mixed solution. Ultrasonic vibration was applied for 0 to 20 min immediately after the soak of the substrate. Then the solution was allowed to be placed in an incubator at  $30^\circ\text{C}$  for 3 d. After soaking, the substrate was washed with distilled water and dried at room temperature. No heat treatment was conducted.

### 2.3 Analysis

The surface of the substrate after soaking was analyzed by thin film X-ray diffraction (TF-XRD: Rint 2500, Rigaku, Japan) and scanning electron microscopy (SEM: ESEM-2700, Nikon, Japan) to investigate the formation of  $\text{ZrO}_2$ . Change of particle size distribution of  $\text{ZrO}_2$  seed crystal due to ultrasonic vibration was analyzed by particle size distribution analyzer (LA-700, HORIBA, Japan).

### 3. RESULTS AND DISCUSSION

Figure 1 shows TF-XRD patterns of surface of the substrate before and after soaking in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution without seed crystal. Without seed crystal, no XRD peak attributed to  $\text{ZrO}_2$  was observed and only halo attributed to glass substrate was observed. No deposition of  $\text{ZrO}_2$  was also confirmed by SEM observation. This indicates that  $\text{ZrO}_2$  was not formed from  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution without seed crystal. Figure 2 to 5 show TF-XRD patterns of surface of the substrate soaked in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution with various amount of seed crystal and ultrasonic vibration for various periods. TF-XRD pattern of substrate before soaking was also given as a reference. XRD peaks attributed to  $\text{ZrO}_2$  was observed for all samples except for the case of  $1.4\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal and 0 min ultrasonic vibration. However the determination of the peak existence is very subtle for this case. Among the samples with 0 min ultrasonic vibration, the peak intensity was correlated with the amount of seed crystal as almost nothing for the sample with  $1.4\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal and maximum for the sample with  $1.4\times 10^{-4} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal. It is clear that seed crystal is effective for the formation of  $\text{ZrO}_2$  from  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution. And taking into consideration of the result that no  $\text{ZrO}_2$  was formed without seed crystal, it can be said that seed crystal is indispensable to the formation of  $\text{ZrO}_2$  from  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution. For the cases of  $1.4\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal,  $6.9\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal and  $9.6\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal, the XRD peak intensity increased with the increase of the period of ultrasonic vibration. It is considered that seed crystals were dispersed by ultrasonic vibration and  $\text{ZrO}_2$  formation was enhanced. For the case of  $1.4\times 10^{-4} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal, the peak intensity was maximal with 10 min ultrasonic vibration, but decreased with longer ultrasonic vibration contrary to the other case. These tendency were also indicated in Fig. 6, which shows intensity of  $\text{ZrO}_2$  main peak versus the period of

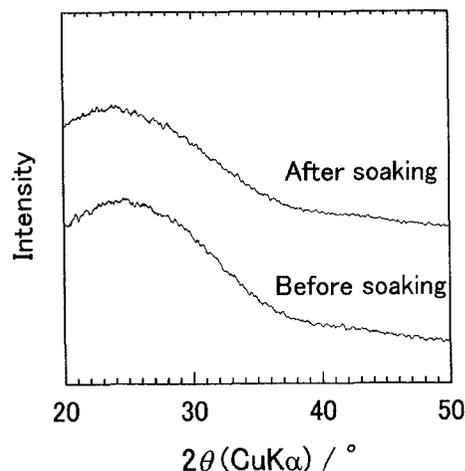


Fig. 1 TF-XRD patterns of surface of the substrate before and after soaking in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution without seed crystal.

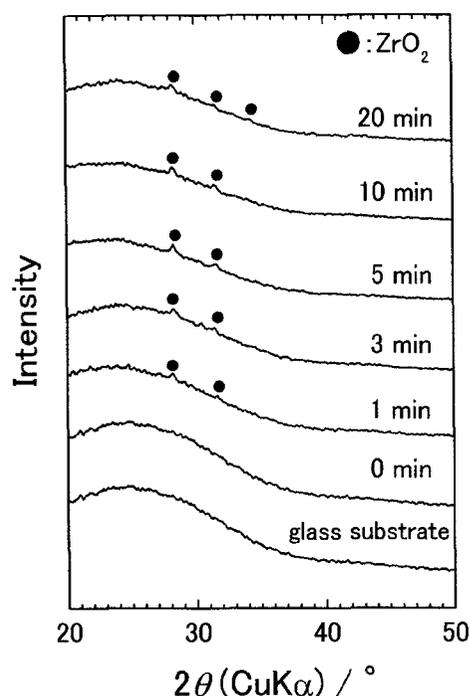


Fig. 2 TF-XRD patterns of surface of the substrate soaked in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution with  $1.4\times 10^{-5} \text{ mol}\cdot\text{dm}^{-3}$  seed crystal and ultrasonic vibration for various periods. TF-XRD pattern of substrate before soaking was also given as a reference.

ultrasonic vibration. It is considered that application of ultrasonic vibration for excessively long period will rather agglomerate seed crystal and reduced the effectiveness when larger amount of seed crystal is added.

The influence of ultrasonic vibration on the particle size of seed crystal was measured by particle size distribution analyzer. The concentration of  $\text{ZrO}_2$  seed crystal was set to  $5.5\times 10^{-4} \text{ mol}\cdot\text{dm}^{-3}$ , which is higher

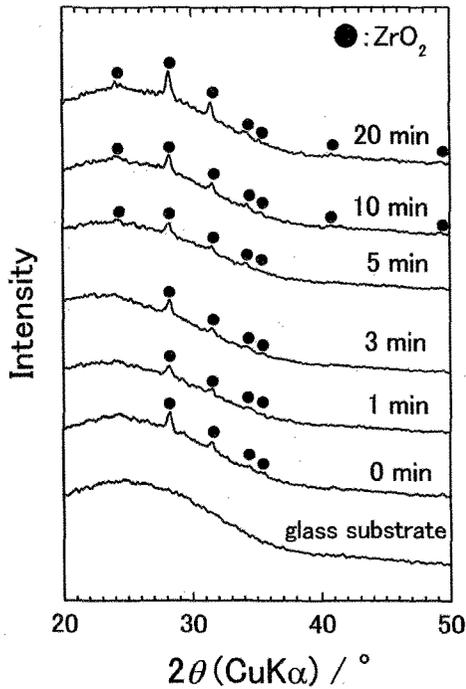


Fig. 3 TF-XRD patterns of surface of the substrate soaked in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution with  $6.9 \times 10^{-5} \text{ mol} \cdot \text{dm}^{-3}$  seed crystal and ultrasonic vibration for various periods. TF-XRD pattern of substrate before soaking was also given as a reference.

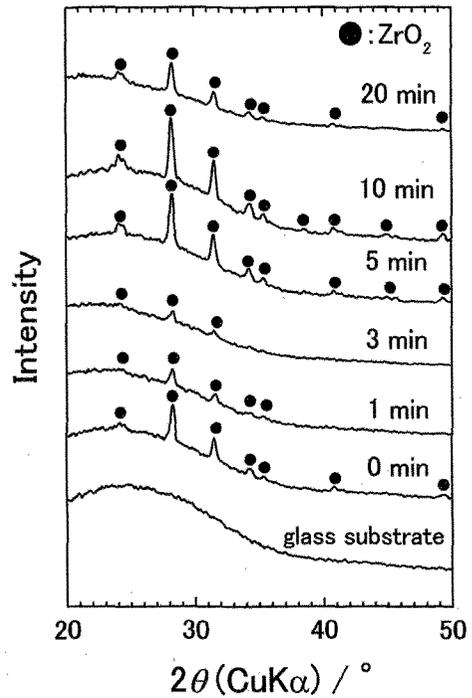


Fig. 5 TF-XRD patterns of surface of the substrate soaked in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution with  $1.4 \times 10^{-4} \text{ mol} \cdot \text{dm}^{-3}$  seed crystal and ultrasonic vibration for various periods. TF-XRD pattern of substrate before soaking was also given as a reference.

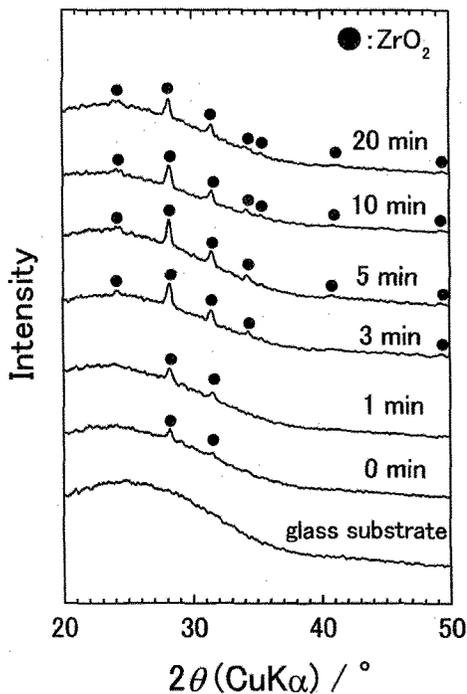


Fig. 4 TF-XRD patterns of surface of the substrate soaked in  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solution with  $9.6 \times 10^{-5} \text{ mol} \cdot \text{dm}^{-3}$  seed crystal and ultrasonic vibration for various periods. TF-XRD pattern of substrate before soaking was also given as a reference.

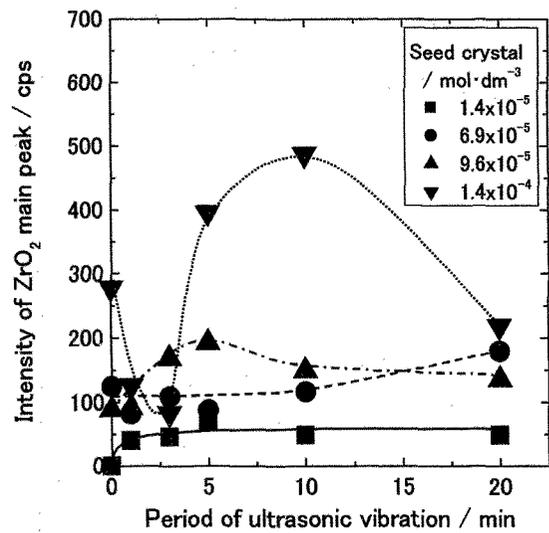


Fig. 6 Intensity of  $\text{ZrO}_2$  main peak versus period of ultrasonic vibration.

than that in any of the  $\text{Na}_2\text{ZrF}_6$  and  $\text{H}_3\text{BO}_3$  mixed solutions, however these were not high enough for the measurement. Figure 7 shows particle size distribution of  $\text{ZrO}_2$  seed crystal with ultrasonic vibration for 1 or 10 min. Without ultrasonic vibration, particle size distribution of  $\text{ZrO}_2$  seed crystal could not be measured, maybe the particle size was less than the detection limit of the equipment. After 1 min ultrasonic vibration, the particle size distribution of  $\text{ZrO}_2$  seed crystal showed

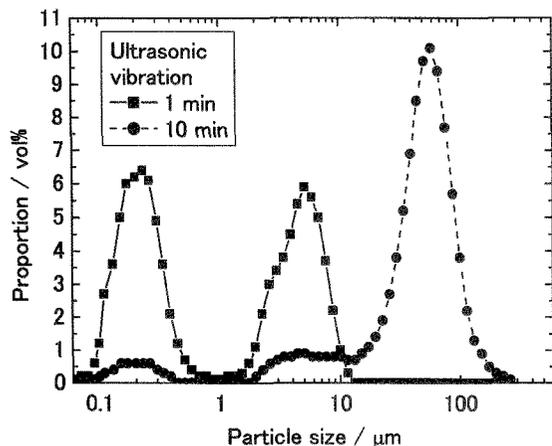


Fig. 7 Particle size distribution of  $ZrO_2$  seed crystal in as-prepared supernatant liquid with ultrasonic vibration for 1 or 10 min

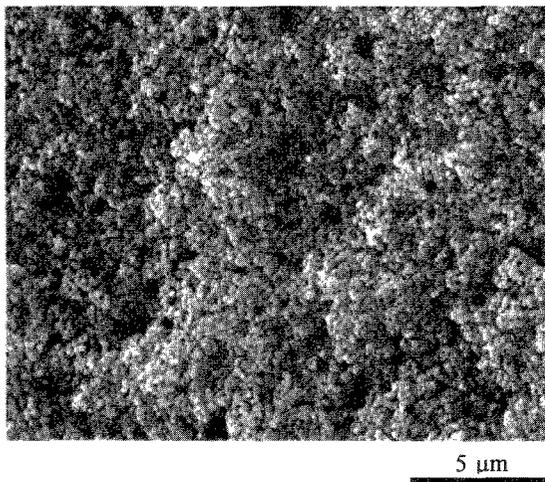


Fig. 8 SEM micrograph of the the substrate soaked in  $Na_2ZrF_6$  and  $H_3BO_3$  mixed solution with  $1.4 \times 10^{-4} \text{ mol} \cdot \text{dm}^{-3}$  seed crystal and ultrasonic treatment for 10 min.

two peaks at around  $0.2 \mu\text{m}$  and  $5 \mu\text{m}$ . This indicates that  $ZrO_2$  seed crystal was already agglomerated after 1 min ultrasonic vibration. After 10 min ultrasonic vibration, the peaks at around  $0.2 \mu\text{m}$  and  $5 \mu\text{m}$  almost disappeared and another new peak at around  $60 \mu\text{m}$  was observed. This indicates that agglomeration of  $ZrO_2$  seed crystal proceeded with the increase of period of ultrasonic vibration. Though the concentration is higher, it is considered that similar aggregation phenomenon occurred in the mixed solution.

Figure 8 shows SEM micrograph of the surface of the substrate soaked in  $Na_2ZrF_6$  and  $H_3BO_3$  mixed solution with  $1.4 \times 10^{-4} \text{ mol} \cdot \text{dm}^{-3}$  seed crystal and ultrasonic vibration for 10 min. It is seen that  $ZrO_2$  particles around  $200 \text{ nm}$  in diameter were deposited all over the surface of the substrate.  $ZrO_2$  particles are observed gathering, growing and connecting with each other to form film-like aggregates.

#### 4. CONCLUSIONS

The effect of seed crystal on the formation of  $ZrO_2$  from  $Na_2ZrF_6$  and  $H_3BO_3$  mixed aqueous solution was investigated. Without seed crystal,  $ZrO_2$  formation was not observed. When seed crystals were added to the  $Na_2ZrF_6$  and  $H_3BO_3$  mixed aqueous solution,  $ZrO_2$  formation was observed and the XRD peak intensity of  $ZrO_2$  increased with the increase of seed crystal amount. It is indicated that the seed crystal is indispensable to the formation of  $ZrO_2$  from  $Na_2ZrF_6$  and  $H_3BO_3$  mixed aqueous solution. Application of ultrasonic vibration immediately after the soak of the substrate enhanced the formation of  $ZrO_2$ , however, application of ultrasonic vibration for excessively long period rather reduced the effectiveness when larger amount of seed crystal was added. In SEM micrograph on the substrate, particles are observed gathering, growing and connecting with each other to form film-like aggregates.

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(Received December 20, 2002; Accepted March 7, 2003)